

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
	:	Prior Examiner: H. Nguyen
Kiyoshi ARAKAWA)	
	:	Prior Group Art Unit: 2851
Application No.: Continuation of Application)	
No. 09/986,918, filed November 13, 2001	:	
)	
Filed: July 14, 2003	:	
)	
For: EXPOSURE APPARATUS, MAINTENANCE	:	
METHOD THEREFOR, SEMICONDUCTOR)	July 18, 2003
DEVICE MANUFACTURING METHOD	:	
USING THE APPARATUS, AND)	
SEMICONDUCTOR MANUFACTURING	:	
FACTORY)	

Mail Stop Patent Application

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

Prior to examination on the merits, please amend the above-identified application as follows:

INTRODUCTORY COMMENTS

This Amendment has been prepared in accordance with the Revised Format established by the U.S. Patent and Trademark Office, as permitted in the Pre-OG Notice dated February 4, 2003, and entitled "Amendments in a Revised Format Now Permitted."